Gauge R&R (JMP) of Xray photoelectron spectroscopy to monitor a coating process

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Background & Problem statement

Operation definition & data collection plan

MSA components analysis

Plan for MSA components improvement



Background

In therapeutic areas (ex. antibiotic, drug/alcohol addiction), daily Injections cause side effects and patients skipping medication.



To solve patient's adherence issue, a potential

approach to tailored release of drug

Team developed AIOx barrier layer that forms a shell around the API particle & controls the release of the drug. Characteristics (**composition** & thickness) of oxide layer can customize the release.

Reporting noise analysis (GRR) of composition (O/AI ratio) measurements



Problem statement / objective and measurement device

- Problem statement: Measure AlOx coating composition (spec O/Al ratio: 1.2-2.3)
- Objective: To determine analysis (XPS) method is adequate to differentiate AIOx process variation Determine GRR of XPS for AIOx composition analysis

Measurement device

- » X-Ray Photoelectron Spectroscopy (XPS) is used to determine quantitative atomic composition
- » XPS measures the kinetic energy of the photoelectrons emitted from elements and counts the electrons

Measurement parameters

- » Counts of electrons for each elements
 - Accounts the presence of elements
 - What other elements bonded with it

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Source of errors	Impact on GRR components
Calibration	Reproducibility
Electron counts	Repeatability & reproducibility
Analysis	Reproducibility

s://www.researchgate.net/publication/357 9594 Recent Trends in Applications of X-



XPS and its detection capability

- Measures energy and electron counts
 - Assess the binding energies (BE) of core-level electrons and the chemical affinity of an atom
- Source of errors in XPS analysis
 - background/baseline corrections
 - Electron counts
 - Peak deconvolution



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polications of X

Hemispherical analyzer

- Recent development to eliminate XPS analysis errors
 - background/baseline corrections
 - eliminate inelastically scattered electrons interference in measurement & improve in accuracy to identify peak position & counts
 - Electron counts
 - Flood gun: neutralize the surface charge during data acquisition
 - Ion gun: clean surface before measurement to eliminate effect of contamination
 - Hemispherical analyzer: different energy electrons arrive at different positions in the radial direction that improve binding energy resolution
 - Peak deconvolution
 - X-ray emission, charge neutralization, resolution, peak fitting software



Operation definition

#	Task	Operation		
	Subject	Measure composition of AIOx coating (O/AI ratio)	Coating	
1.	Baseline correction	Automatic		
2.	Calibration	XPS spectra adjusted with carbon peaks (C1s = 284.8 eV, C-C,H)	API particles	
3.	XPS scan	XPS survey & high-resolution scan,	Substrate not for	Substrates for XPS
4.	Analysis	Peak fitting, quantize at% and determine O/AI ratio	XPS measurement	measurement

Calibration with C-peak

No calibration sample available Human error associated impact on reproducibility



XPS scan

affected by baseline correction (automatic) /calibration (manual) that impact on repeatability & reproducibility



Analysis

Peak fitting semi-automatic. impact on reproducibility



Most of state-of-the-art XPS tools are semiautomatic and human error is associated with sample loading, calibration and peak fitting

MSA C&E diagram

Parameters that impact on GRR of XPS for AIOx composition analysis

- » System calibration: XPS scan affected by calibration and under or overestimate elements at% (impact on reproducibility)
- » XPS scan (electron counts): Effect on peak position as well peak area depending on baseline correction & calibration (impact on repeatability & reproducibility)
- » Analysis Peak fitting: Generate error in the proportion of elements at% (Impact on reproducibility)
- » Sample: process variation with substrate

JMP Platform: Analyze > Quality and Process > Diagram



Data Collection plan

- Sampling Method:
 - » 2 sites for XPS analysis (O/Al ratio)
 - » 6 samples (parts) (S0, S1, S2, A0, A1, A2)
 - » 4 replicates of each sample measured at each site
- Expected outcome:
 - » 2 sites get similar results
 - » Sample (part) not interact with site
 - » XPS method is adequate to differentiate process variation (O/AI ratio)
- Risk assessment
 - » O/Al ratio degradation with time

Total	10	moseuromonte
TOLA	40	measurements

	A3 AMAT e File Edit Ta	xample_SC mo	ore data in Cols D0	MSE design style DE Analyze Grap	JMP — oh Tools	□ View	imesWindow	
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\sim	⊿ 7/0 Cols 💌							
(2)	\sim \sim \sim	Sample ID	Site	substrate type	0%	AI%	O/AI	-
		A0-1	Site A	API pallet	66.6	39.1	2.1	
t i		A0-3	Sice o	5				
		A0-4						
		A1-1						
	💌 48/0 Rows 🛝	19 others			53.2	31.2	1.49	
	1	A0-1	Site A	API pallet	64.1	31.2	2.05	^
	2	A0-2	Site A	API pallet	63.1	32.9	1.92	
4 replicates	3	A0-3	Site A	API pallet	64.8	31.9	2.03	
	4	A0-4	Site A	API pallet	65	32.2	2.02	
	5	A0-1	Site B	API pallet	64.8	32.9	1.97	
	6	A0-2	Site B	API pallet	65.2	33.5	1.95	
	7	A0-3	Site B	API pallet	66.8	34.5	1.94	
	8	A0-4	Site B	API pallet	65.4	32.5	2.01	
	9	A1-1	Site A	API pallet	57.6	36.1	1.60	
	<mark>1</mark> 0	A1-2	Site A	API pallet	55	34.5	1.59	
	11	A1-3	Site A	API pallet	58	39	1.49	
	12	A1-4	Site A	API pallet	56.2	36.7	1.53	
	13	A1-1	Site B	API pallet	57.8	38.9	1.49	
	14	A1-2	Site B	API pallet	58	39	1.49	
	15	A1-3	Site B	API pallet	59.2	38.1	1.55	
	16	A1-4	Site B	API pallet	57.4	37.4	1.53	
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	evaluations do	10				8 ^		
	craidations doi							1111

MSA design

Substrate type & site both are Crossed factors

MSA design window

Recnances						
Add Response R	emove Number o	of Responses				
Response Name	·······	Goal	Lower Limit	Upper Limit	Importance	
O/Al ratio		Match Target	1.2	2.3		
				6 narte	· SU S1	S 2
				o parto		$0\mathbf{Z},$
Factors				$\Delta \cap \Delta 1$	and $\Delta 2$	
Add Factor Add N Fa	ctors 1	Remove	/	$\Lambda 0, \Lambda 1$		
Show Levels		Hernove			1	
Name	MSA Role	# of Levels	Random	78		
Sample ID	Part	6	Yes			
	Operator	2	Yes			
L Vendor						
📕 Vendor						
d Vendor				Queiteer		
Vendor mber of Replicates	Replicate Rups			2 sites:	A & B	
Vendor	Replicate Runs	harimahau		2 sites:	A & B	
Vendor	Replicate Runs — Completely R Batch Repeat	andomized		2 sites:	A & B	

- » Not be able to use completely randomized option – risk: minimizing noise
- » Fast repeat option Not changing sample replicate # - risk: sample degradation
 - Compare 1st and 4th replicates to retire sampling risk

- MSA fast repeat table: 48 rows
 - Sample size is more than necessary from the perspective of power

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 MSA Design 	0 0 🦉			L L		1
Design MSA Desig	n 💌 🖳	Run Order	Substrate type	Site	Fast Replicate	O/Al ratio
 EMP Measurtems Analysi Variability Chart 	s 1	1	S0	Vendor	^A Measured in ¹	1
Design Structure	2	2	S0	Vendor	Asequence 2	Not
DOE Dialog	3	3	S0	Vendor	A 3	completely
Operator Worksheets	4	4	S0	Vendor	A 4	randomized
	5	5	S0	Vendor	6	
	6	6	50	Vendor	B 2	
Columns (5/0)	7	7	S0	Vendor	B 3	
1	8	8	50	Vendor	B 4	
Run Order	9	9	S2	Vendor	B 1	
Substrate type	10	10	S2	Vendor	B 2	
East Replicate	11	11	S2	Vendor	B 3	
O/Al ratio *	12	12	S2	Vendor	B 4	
	13	13	S2	Vendor	A 1	
 Rows 	14	14	S2	Vendor	A 2	
All rows 4	8 15	15	52	Vendor	A 3	
Selected	0 16	16	S2	Vendor	A 4	
-xciudea Hidden	17	17	A2	Vendor	A 1	
Labeled	0 18	18	A2	Vendor	A 2	
	19	19	A2	Vendor	A 3	

Sequence of JMP analysis for MSA

#	Task to do	Application to use	JMP Platform
	Data distribution of MSA samples	Descriptive and inferential statistics	Distribution & Fit Y by X
2.	Data variability – common cause vs. special cause	I-MR & One-way ANOVA	Control charts & Fit Y by X
3.	GRR components	Gauge R&R method	Variability
4.	Process capability (Cp) with GRR	ICC vs P/T – EMP method	Measurement system analysis
5.	Improve GRR components	Box plot, density ellipse, Fit line & matched pairs	Distribution, Fit Y by X & Specialized modeling

JMP Platform: Analyze > Distribution & Fit Y by X

MSA sample distribution

JMP analysis identified overall data distribution is bimodal. Data from each section has normal distribution

Spec limits: O/Al - 1.2-2.3



uniform distribution

Variability in O/AI I Identify candidate for subgrouping ^{JM} To identify special cause of variation

I-MR chart

Mix up common cause variation (equipment variation or repeatability) and special cause variation (site or part variation), control limits here are meaningless. Need subgrouping with special cause



One-way ANOVA

Is part variation special cause?



JMP Platform: Analyze > Quality and Process > Control Chart Builder (LHS) & Variability (RHS)

Variability in O/AI I Identify candidate for subgrouping

JMP Platform: Analyze > Quality and Process > Control Chart Builder (LHS) & Variability (RHS)

I-MR chart

Mix up common cause variation (equipment variation or repeatability) and special cause variation (site or part variation), control limits here are meaningless. Need subgrouping with special cause



One-way ANOVA

Is site variation special cause?



Either P> 0.05 (no evidence to reject) or P <0.01(marginally reject) Site variation is marginal, not a good candidate for

subgrouping. Part variation is better candidate

JMP Platform: Analyze > Quality and Process > Control Chart Builder

Variability in O/AI I subgrouping with part by site Visualize of repeatability & reproducibility

I-MR chart with phase option (part ID)

- » Limited data points (4 only) in each phase. No data point outside control limit
- » Bottom charts moving range indicates variability in each subgroup and forms control limits of upper chart
- » Upper charts control limit varies with phase and site indications of variation in repeatability and reproducibility





JMP Platform: Analyze > Quality and Process > Variability

Crossed (ANOVA with Interaction)

GRR analysis

Repeatability is dominating error over reproducibility

Main Effect (ANOVA without Interaction)

Gauge R&R									Gauge R&R		
Measurement Source		Variation (6*StdDev)	% of Tolerance		which is 6*sqrt of				Measurement Source		Variati
Repeatability Reproducibility Operator Gauge R&R Part Variation Total Variation Total Variation & Summary and 6 k 20.1543 % G 0.20577 Prec 6 Nur 1.2 Low 2.3 Upp	(EV) (AV) (RR) (PV) (TV) Gauge auge F ision 1 hber o er Tole	0.2419131 0.1623625 0.1623625 0.2913478 1.4159201 1.4455841 e R&R Statistii R&R = 100*(R to Part Variatio f Distinct Cate erance (UT)	21.99 14.76 14.76 26.49 128.72 131.42 cs R/TV) pn = RR/PV egories = Floo	Equipment Variation Appraiser Variation Measurement Variation Part Variation Total Variation	V(Within) V(Operator) V(Operator) on V(Within) + V(Operator) V(Sample ID) V(Within) + V(Operator) +	V(Sample ID)			Repeatability Reproducibility Operator Operator*Sample II Gauge R&R Part Variation Total Variation Summary and Gau 6 k 21.2463 % Gauge 0.21743 Precision 6 Number 1.2 Lower	(EV) (AV) (RR) (PV) (TV) ge R&R R&R = to Part of Distin	0.2348; 0.1107(0.0887; 0.0662; 0.2596 1.1940 1.2219 Statistics 100*(RR/I t Variation nct Catego
1.1 Tole 0.26486 Prec	ision/	= UT-IT Tolerance Rati	io = RR/(UT-	LT)	Misclassification Probab Lower Tolerance = 1.2, Upper T	ilities olerance = 2.3, Gra	nd Mean = 1.709167	1	2.3 Upper To 1.1 Tolerance 0.23601 Precision	lerance e = UT-I /Tolera	(UT) LT ince Ratio
Variance C	omp	onents for	Gauge Ra	&R	Description P(Good part is falsely rejected	Probability 0.00640770	Type I	error (α)	Using last column 'Sa	mple ID)' for Part.
		Var			P(Bad part is falsely accepted)	0.16233021		$\operatorname{error}(\mathfrak{g})$	Variance Com	poner	nts for G
Component Gauge R&R Repeatabilit Reproducibi Part-to-Part	/ lity	Component 0.00235788 0.00162561 0.00073227 0.05568972	% of Total 4.06 2.80 1.26 95.94		P(Part is good and is rejected) P(Part is bad and is accepted) P(Part is good)	0.00820913	It's cu Have	stomer call. option to	Component Gauge R&R Repeatability Reproducibility Part-to-Part	Compo 0.001 0.001 0.000 0.039	Var onent % 87217 53171 34046 960231
							impro	ving repeatab	ilitv		



GRR marginally passed. Type II error is 18%, we have option to improve GRR



JMP Platform: Analyze > Quality and Process > Measurement system analysis

Relation of process capability (Cp) with GRR ICC vs P/T Intraclass correlation



co-efficient

$$ICC = \frac{\sigma_{part}^2}{\sigma_{part}^2 + \sigma_{gauge}^2}$$

$$P/T = \frac{6\hat{\sigma}_{gauge}}{USL - LSL}$$

Part variance in total variance

Spec based GRR

- Cp <1 (red zone)</p>
- ICC is high and P/T is 24%
- To improve Cp into yellow zone, P to be improved
 - » Repeatability to be improved since it is major error factor

JMP Platform: Analyze > Quality and Process > Measurement System Analysis

EMP analysis

Main vs. Crossed model: parameters values are not changing much since part*vendor interaction is minor

MP Results						
MP Test		Results D	escrip	tion		
ast-Retest Error		0.0403 W	Vithin	Error		
egrees of Freedo	m	41 A	moun	t of information used to e	stimate within error	
robable Error		0.0272 N	ledian	error for a single measure	ement	
traclass Correlati	on (no bias)	0.9716 P	roport	ion of variation attributed	d to part variation without	including bias factors
traclass Correlati	on (with bias)	0.9594 P	roport	ion of variation attributed	d to part variation with bias	factors
as Impact		0.0123 A	moun	t by which the bias factor	s reduce the intraclass con	elation
	Charlentin					
urrent (with hise)	First Class					
otential (no bias)	First Class					
Monitor Clas	sification L	egend				
	Intraclass	Attenuatio	on of	Probability of	Probability of	
Classification	Correlation	Process Si	gnal	Warning, Test 1 Only*	Warning, Tests 1-4*	
First Class	0.80 - 1.00	Less than 1	1%	0.99 - 1.00	1.00	
Second Class	0.50 - 0.80	11% - 29%	2	0.88 - 0.99	1.00	
Third Class	0.20 - 0.50	29% - 55%		0.40 - 0.88	0.92 - 1.00	
Fourth Class	0.00 - 0.20	More than	22%	0.03 - 0.40	0.08 - 0.92	
* Probability	of warning fo	r a 3 standa	ard er	or shift within 10 subgr	oups using	
Wheeler's te	sts, which cor	respond to	Nelso	on's tests 1, 2, 5, and 6.		
ffective Resol	ution					
ource			Valu	e Description		
robable Error		(PE)	0.027	2 Median error for a sing	le measurement	
ower Bound Incre	ement	(0.1*PE)	0.002	7 Measurement increment	nt should not be below this	s value
mallest Effective I	ncrement	(0.22*PE)	0.00	6 Measurement increment	nt is more effective above t	this value
urrent Measurem	ent Increment	(MI)	0.0	1 Measurement increment	nt estimated from data (in f	(enths)
rgest Effective In	crement	(2.2*PE)	0.059	8 Measurement increment	nt is more effective below t	his value
tion: Use as is						

Crossed effect (ANOVA with Interaction)

EMP Test		Results De	scriptio	on					
Test-Retest Error		0.0445 Wit	thin Erro	or					
Degrees of Freedon	n	33.098 Am	nount o	f information used to e	estimate within error				
Probable Error		0.03 Me	0.03 Median error for a single measurement						
Intraclass Correlatio	on (no bias)	0.9473 Pro	oportion	of variation attributed	d to part variation without in	ncluding bias factors			
Intraclass Correlatio	on (with bias)	0.9296 Pro	oportion	n of variation attributed	d to part variation with bias	factors			
Bias Impact		0.0177 Am	nount b	y which the bias factor	s reduce the intraclass corre	lation			
System	Classification								
Current (with bias)	First Class								
Potential (no bias)	First Class								
Monitor Class	ification Le	egend							
	Intraclass	Attenuation	n of P	robability of	Probability of				
Classification	Correlation	Process Sign	nal W	Varning, Test 1 Only*	Warning, Tests 1-4*				
First Class	0.80 - 1.00	Less than 11	1% 0.	.99 - 1.00	1.00				
Second Class	0.50 - 0.80	11% - 29%	0.	.88 - 0.99	1.00				
Third Class	0.20 - 0.50	29% - 55%	0.	.40 - 0.88	0.92 - 1.00				
Fourth Class	0.00 - 0.20	More than 5	5% 0.	.03 - 0.40	0.08 - 0.92				
* Probability o Wheeler's tes	of warning for sts, which corr	a 3 standar respond to N	d error Velson'	shift within 10 subgr s tests 1, 2, 5, and 6.	oups using				
ffective Resolu	ition								
Source			Value I	Description					
Probable Error		(PE)	0.03 1	Median error for a sing	le measurement				
Lower Bound Incre	ment	(0.1*PE)	0.003	Measurement incremen	nt should not be below this	value			
Smallest Effective In	ncrement	(0.22*PE) 0	0.0066	Measurement incremer	nt is more effective above th	nis value			
Current Measureme	ent Increment	(MI)	0.01	Measurement increment	nt estimated from data (in te	enths)			
Largest Effective In	crement	(2.2*PE) 0	0.0661	Measurement incremer	nt is more effective below th	nis value			
Action: Use as is									

Variation in O/Al ratio | Site (Operator)

JMP Platform: Analyze > Quality and Process > Variability

Repeatability & reproducibility in variability chart



Source of measurement error

Repeatability impacted by	Reproducibility impacted by
Base line correction	Calibration
Detector difference	Analysis

Variability chart and Analysis of variance confirmed Repeatability is bigger problem than reproducibility

» To improve GRR, need root cause analysis of repeatability

Source	DF	SS	Mean Square	F Ratio	Prob > F
Site	1	0.0192	0.0192	11.811	0.0014*
Sample ID	5	2.235717	0.44714	275.062	<.0001*
Within	41	0.06665	0.00163		
Total	47	2.321567	0.0494		

P<0.05 indicates site to site variation in analysis

Root cause analysis I Why high repeatability

Compare repeatability variation @ part and site



Repeatability varies from part to part and Site to site



Site variation could be due to:

- 1. Calibration
- 2. XPS scan
- 3. Analysis



Near LSL



JMP Platform: Graph > graph Builder

JMP Platform: Analyze > Fit Y by X **Root cause analysis | Relationship of Site A and Site B**

Test correlation and linear fit: site A vs. site B



1.65

16

Root cause analysis | Compare each measurement

JMP Platform: Analyze > Specialized Modeling > Matched Pairs

Difference in each measurement – Site A vs. Site B



JMP Platform: Analyze > Distribution

Matched pairs model

» P<0.05

Site A measurement significantly different from Site B

Part and site interaction is observed



Root cause analysis I Risk of part degradation

JMP Platform: Analyze > Specialized Modeling > Matched Pairs

1st vs. 4th replicate – Site A and Site B



Matched pairs model

- » P>0.05
- » Eliminated risk of part degration

No evidence of part degradation between 1st and 4th replicates



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Root cause analysis | Dashboard Summary

Why repeatability is a key problem

 P/T (24%) & repeatability (21%) are high since repeatability varies part to part and site to site





MSA improvement plan

With Site

- » Issue # 1: Repeatability
- » Issue # 2: Part Site interaction
 - Source of errors
 - background/baseline corrections
 - Electron counts
 - Peak deconvolution
 - Discuss to set up calibration sample
 - One set of samples measure in regular time interval

With process team

- » Issue # 3: MSA sample collection
- » Issue # 4: Part to part repetability
 - MSA samples at two spec limits could underestimate MSA components (repeatability & reproducibility) – requirement of MSA samples throughout the whole spec
 - Validate thermal map for process uniformity

Learnings & Impact

Learnings – data driven measurement method validation

- » Separating out signal variation from noise variation
- » Identification of specific GRR figure of merit to justify measurement method
- » Misclassification risks related with MSA components
- » Root cause analysis for improving MSA

Improve culture & practices – data driven decision making

- » As a regular practice, apply JMP analysis to all the programs involved for improving project quality, cost and time
- » Promote data driven decision (JMP) making in Advance Technology Group



On going

- Enrolled for AMAT Black Belt certification
- Participating and presenting in US JMP Discovery Summit Oct 2023
- Completed STIPS certification



